PATENT 8075-1015

in the u.s. patent and trademark office0/552709

In re application of

Rikizo HATAKEYAMA et al.

Conf.

Application No. NEW NATIONAL PHASE

Group

Filed October 7, 2005

Examiner

METHOD AND APPARATUS FOR PRODUCING GAS ATOM CONTAINING FULLERENE, AND GAS ATOM CONTAINING FULLERENE

INFORMATION DISCLOSURE STATEMENT (SUBMISSION CONCURRENT WITH THE FILING OF A NEW PATENT APPLICATION)

Assistant Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

October 7, 2005

Sir:

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Pursuant to 37 C.F.R. §§ 1.97 and 1.98, and in fulfillment of the duty of disclosure under 37 C.F.R. § 1.56, applicant(s) hereby submit(s) an Information Disclosure Statement for consideration by the Examiner.

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INFORMATION DISCLOSURE CITATION IN AN APPLICATION

Attorney Docket No.: 8075-1015

Application No.: **NEW NATIONAL PHASE**

Applicant:

Rikizo HATAKEYAMA et al 1552709

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not in conformance and not considered. Include copy of this form with next communication to the applicant.

^{*} English language abstract provided for the Examiner's convenience